



In re PATENT APPLICATION of

Jae-dong Lee et al.

Serial No.: 10/023,948

Filed: December 21, 2001

CHEMICAL MECHANICAL POLISHING SLURRY

RESPONSE TO ELECTION/RESTRICTION REQUIREMENT

Honorable Commissioner of Patents and Trademarks, Washington, D.C. 20231

Sir:

In response to the Office Action of March 20, 2003, Applicants elect the invention of Group I, Claims 1-12, drawn to polishing slurry. The election is without traverse.

Respectfully submitted.

VOLENTINE FRANCOS, PLLC

Group Art Unit: 1765

Examiner: Lynette T. Umez Eronin

Adam C. Volentine Registration No. 33,289

12200 Sunrise Valley Drive, Suite 150

Reston, Virginia 20191

Telephone No.: (703) 715-0870 Facsimile No.: (703) 715-0877

Dated: April 8, 2003